

## <u>IN THE UNITED STATES PATENT AND TRADEMARK OFFICE</u>

In re the Application of: Koji NOZAKI et al.

Group Art Unit: 1752

Application Number: 10/623,679

Examiner: Amanda C. Walke

Filed: July 22, 2003

Confirmation Number: 5083

For:

RESIST PATTERN THICKENING MATERIAL, RESIST PATTERN

AND PROCESS FOR FORMING THE SAME, AND SEMICONDUCTOR DEVICE AND PROCESS FOR

MANUFACTURING THE SAME

Attorney Docket Number:

030891

Customer Number:

38834

## PETITION FOR EXTENSION OF TIME

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450 November 13, 2006

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated July 10, 2006 for one month from October 10, 2006 to November 10, 2006.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP 00000068 10623679

02 FC:1251

120.09 OP

Shuji Yoshizaki

Limited Recognition

Telephone: (202) 822-1100 Facsimile: (202) 822-1111